

10/729479

**EAST Search History**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	10/729479	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 19:56
L2	4	2002/0046985	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 19:56
L3	2	("4597166").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 19:56
L4	2	("5294559").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 20:04
L5	4	2 and (integrated or circuit or strain or straine or layer or insulating or semiconductor or pillar or pillars or direction or plurality or closer or perpendicular or parallel or base or height or greater or width or top or surface or opposite or active or component or trnch or trenches or device or etch or etching or inducing or stress)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 20:10
L6	2	3 and (integrated or circuit or strain or straine or layer or insulating or semiconductor or pillar or pillars or direction or plurality or closer or perpendicular or parallel or base or height or greater or width or top or surface or opposite or active or component or trnch or trenches or device or etch or etching or inducing or stress)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 20:12

## EAST Search History

L7	2	4 and (integrated or circuit or strain or straine or layer or isnulating or semiconductor or pillar or pillars or direction or plurality or closer or perpendicular or parallel or base or height or greater or width or top or surface or opposite or active or component or trnch or trenches or device or etch or etching or inducing or stress)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/11/03 20:12
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